Solar cell demand for bifacial and singulated-cell module architectures

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ABSTRACT

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PV Modul<u>es</u> The pursuit of achieving higher power output of silicon-based PV modules demands creative improvements in module design in order to reduce geometrical, optical and electrical cell-to-module (CTM) losses. A suitable method, which has been known since Dickson's patent in 1956 (but has been mostly under the radar of the manufacturing industry), is the shingling of singulated solar cell stripes. This technology offers three advantages in comparison to modules with standard-sized solar cells. First, blank cell spacing in the module is minimized, thus increasing the power-generating area per module area. Second, the active cell area is busbar-less, which leads to reduced shading losses. Third, because of the smaller area of the solar cell stripes, the generated current per cell is less, which results in a reduction in the overall series resistance of the cell interconnection within the module. To boost the power output of such a shingled module even further, the introduction of bifacial properties is suggested. To make this bifacial shingled module technology visible on the industry's radar, a practical concept is essential; this paper presents, step by step, Fraunhofer ISE's approach for a bifacial shingled module. Suitable bifacial cell concepts - such as passivated emitter and rear (PERC), passivated emitter, rear totally diffused (PERT), and passivated emitter, rear locally diffused (PERL) - are briefly introduced. The PERL cells are based on the PassDop approach, in which the rear-side passivation layer stack also acts as a doping source during local laser doping. Furthermore, next-generation bifacial cell concepts based on selective and/or passivated contacts, such as in the already established silicon heterojunction technology (SHJ) and the tunnel oxide passivated contact (TOPCon) approaches, developed at Fraunhofer ISE, are presented. Laser-assisted cutting as the singulation technology for realizing the cell stripes, and the challenge of charge-carrier recombination at the cutting edges, are discussed. A bifacial simulation model is presented for the singulated shingle solar cells, covering the question of the impact of different recombination factors, bifacial gains and optimizations of the cell layout. Finally, the module assembly, as well as a detailed calculation of module output power and a comparison with standard module layouts, is presented. This comparison emphasizes the advantages offered by bifacial shingled modules, with the potential to achieve a module power of 400W with a power density of 240W/m² and beyond, for irradiance intensities of 1,000W/m² and 100W/m² from the front and rear sides respectively.

Introduction

The first appearance of a shingled solar cell interconnection pattern (see Fig. 1) dates back to 1956 with a US patent filed by Dickson [1] for Hoffman Electronics Corporation, which is just two years after the first publication of a silicon solar cell by Chapin et al. [2]. In the years that followed, further patents were filed containing concepts of shingling solar cells serving various module designs and applications - for example, Nielsen [3] for Nokia Bell Labs, Myer [4] for Hughes Aircraft Company, Baron [5] for Trw Inc, Gochermann and Soll [6] for Daimler-Benz Aerospace AG, Yang et al. [7] for Silevo LLC, and the most recent patent applications by Morad et al. [8-10] for SunPower Corporation in 2016. Besides the patents, there are a number of items in the literature that have been devoted to this topic in the last few years, with publications by Zhao et al. [11], Glunz et al. [12] and Beaucarne [13]. Recently, the first

widely available commercial shingled module was introduced by SunPower [14] as their top-of-the-line product; according to the data sheet, these modules feature a backsheet and are therefore not bifacial.

The idea of singulated solar cells interconnected by a shingling design

is therefore by no means new. The early publications of shingling approaches were mostly motivated by particular design requirements, such as modules that were curved, triangular [4] or dome shaped [6]. Later publications started to make use of the potential for achieving



silicon solar cells, taken from Dickson's patent [1] (the descriptive labels in the original image have been removed for reasons of clarity).

higher module power densities with this technique than with standardmodule cell interconnection, for example in the limited available space on the vehicle for the 'World Solar Challenge' in 1996 [11]. Consequently, a few large module manufacturers [7,14] seem to have rediscovered the potential of shingling technology to reduce cell-to-module (CTM) losses. The International Technology Roadmap for Photovoltaic (ITRPV) 2017 projects a world market share of 7% for shingled interconnection technology by 2027 [15].

"The opportunity is at hand for combining bifacial solar cell technology with shingle cell module technology."

Another line of technological evolution spreading in the PV industry is the concept of bifacially illuminated solar cells, which has been extensively covered in a recent article by Kopecek and Libal [16]. As the demand for modules with high power density is large, the opportunity is at hand for combining bifacial solar cell technology with shingle cell module technology, with bifacial cells profiting from additional light coming from the rear side. The busbars on the front and rear sides for the shingle cells are covered by an active area from the adjacent cells, leading to a virtually busbar-free cell string.

The approach for such a bifacial shingle module is presented in three stages. First, eligible bifacial cell concepts – including passivated emitter and rear (PERC [17]), passivated emitter, rear totally diffused (PERT [18]), and passivated emitter, rear locally diffused (PERL [19]) – will be discussed. For this study, the PERL concept is based on the PassDop approach [20-22], in which the rear-side passivation layer stack - i.e. the layer stack consisting of aluminium oxide (AlO_x) and boron-doped silicon nitride (SiN_x:B) - also serves as a doping source for local laser doping. Furthermore, cell concepts with selective and/or passivated contacts that are based on silicon heterojunction (SHJ [23]) or hybrid PERC structures with tunnel oxide passivated contacts (TOPCon [24]) on the rear side will be discussed. Second, physically and technically relevant challenges for the transition from standard cells



modules, starting from bifacial cells on a standard-sized wafer with an edge length of 156mm. (a) Six shingle solar cells are placed on the large-area wafer. The cell concept is modular; silicon heterojunction (SHJ), TOPCon and PERC examples are shown here. (b) The individual shingle cells are singulated into cell stripes. (c) A magnified single shingle cell. (d) Cell stripes are shingled onto each other to form a string.



Figure 3. Schematic cross sections of seven different silicon solar cell types with homogeneous emitter. (a) Aluminium back-surface field (AI-BSF) cell. (b) Monofacial PERC with local rear-side contacts. (c) Bifacial PERC with finger grid on the rear side. (d) Bifacial PERT concept with full-area rear-side BSF. (e) Bifacial pPassDop concept with local laser-boron-doped BSF. (f) Silicon heterojunction (SHJ) cell with doped amorphous silicon emitter and a transparent conducting oxide (TCO) as anti-reflection layer. (g) Bifacial TOPCon cell with passivated rear-side contacts (the bifacial rear side shown is only a concept at the moment).

to stripe cells will be addressed, including a discussion of edge recombination effects with a suitable full-cell simulation model realized with the Quokka3 tool [25]. Third, module integration strategies and CTM-loss calculations are provided.

As a name convention, the term 'output power density' P_{out} (mW/cm²) will always be used instead of 'energy conversion efficiency' η (%) for measurement data referring to bifacial illumination, as that unit is less ambiguous. The scale chosen is such that, with a monofacial irradiation of 1,000W/m², the respective numerical values for P_{out} and η are identical.

Approach

Cell

Processing

To achieve a module output power P_{module} of 400W with power densities of 240W/m² and beyond for a standard 60-cell module with a size of 1.68m × 1.00m (irradiation intensities of 1,000W/m² and 100W/m² from the front and rear sides respectively), the approach proposed here is to apply shingling technology in order to use the module area as efficiently as possible. By shingling the solar cells, three CTM-related types of loss are minimized, namely 1) losses due to inactive module area; 2) shading losses due to busbar contacts; and 3) series resistance losses due to cell interconnection. To also benefit from the additional rear-side illumination from bifacial solar cell architectures, the proposed shingle solar cell and module technology is also bifacial in nature. The authors foresee a large potential for this bifacial shingling approach in cases where the 'old idea' of shingled modules can be merged with state-of-the art bifacial solar cell concepts.

To raise interest with regard to industrial mass production, standardsized solar cell manufacturing sequences, with only minor adaptations, should be utilized for the manufacturing of shingle solar cells. Thus, the most obvious industrial solar cell concept to be used is the bifacial passivated emitter and rear cell (biPERC) technology, utilizing p-type Czochralski-grown silicon (Cz-Si) wafers. Fig. 2 illustrates four different typical stages of the fabrication of shingle solar cells and module strings, starting from a standard wafer with an edge length of 156mm. The general approach here is to create a certain number (six in this example) of shingle solar cells on a large-area wafer.

After metallization and contact



formation, the cell stripes are singulated by a laser-assisted cutting process. Subsequently, the single cell stripes are interconnected by shingling the cells onto each other. Since singulation into stripe cells results in an increased contour-toarea ratio, edge passivation becomes important and needs to be considered. This design approach will be called the shingled passivated edge, emitter and rear (SPEER) solar cell concept. A true indication of strength of the module assembly of shingle cells is the modularity of the chosen cell concept to be utilized; the shingle module concept can therefore directly profit from progress in solar cell efficiency, while keeping the same module platform, and thus the same module manufacturing process.

Apart from the SPEER solar cells (which can be based on PERC, PERT or PERL structures), approaches with passivated contacts (SHJ, TOPCon) are within the scope of the work currently being pursued at Fraunhofer ISE. The shingle solar cells that are based on passivated contact approaches are called the *shingled passivated edge, emitter, rear and contact (SPEERCon)* solar cell concept.

Eligible bifacial cell concepts

At the moment, aluminium backsurface field (Al-BSF) solar cells (see Fig. 3(a)), with a market share of around 80% in 2016 [15], still dominate the industrial production of crystalline silicon solar cells. However, the passivated emitter and rear cell (PERC) [17] (see Fig. 3(b)) allows higher energy conversion efficiency as a result of its dielectrically passivated rear side. The market share for PERC has gradually increased, to about 15%, in the last few years, and is expected to win significant market share over Al-BSF technology in the future [15]. Besides the dielectric rear-side passivation, one of the main features distinguishing PERC from Al-BSF cells is the local contacts on the rear side. On the Fraunhofer ISE PV-TEC pilot line [26], the baseline PERC process has yielded energy conversion efficiencies of 21.0% to 21.5% on p-type Cz-Si with a homogeneous emitter and a 156mm edge length [27– 29].

A bifacial solar cell can harvest additional light coming from the rear side (depending on albedo) [16], if an appropriate module concept, such as a glass-glass module, is used. Bifacial cell and module technology therefore offers a higher energy yield potential in cases where the energy conversion efficiency of the front side of the cells is not significantly influenced by the bifacial approach, and is thus on a similar level to their monofacial cell counterparts. Hence, reducing the metallized rear-side area from a full-area metallization, as commonly employed for PERC cells, to a metallization grid is a logical technological adaptation (Fig. 3(c)). With a metallization grid on the rear side instead of a full-area metallization, the bifacial application is enabled, and the adapted cell structure is referred to as *biPERC*.

The potential of PERC-like bifacial cell architectures was shown on cells in the laboratory back in the 1990s [30–32]. Industrial large-area p-type biPERC cells with a screen-printed aluminium rear-side grid were first realized on multicrystalline silicon in 2016, achieving an efficiency of $\eta = 17.8\%$ [33]. Subsequently, biPERC solar cells utilizing p-type

Cell type	Cell area [cm²]	Material	Finger width rear side [µm]	Monofacial illumination	V _{oc} [mV]	j _{sc} [mA/cm²]	FF [%]	N _{mean} [%]	η _{max} [%]	Bifaciality factor [%]
biPERC*	243	p-type Cz-Si	100	Front	660	39.5	79.3	20.7	20.7	76.8
				Rear	654	30.7	79.6	15.9	16.4	
			150	Front Rear	660 652	39.5 28.8	79.8 80.1	20.8 15.0	20.9 15.5	72.1
			200	Front Rear	661 651	39.5 26.6	79.9 80.3	20.9 13.8	21.0 14.2	66.0
Monofacial PERC*			-	Front	656	39.8	80.0	20.9	21.1	-
biPERT*	243	p-type Cz-Si	200	Front	654	39.5	79.3	20.4	20.5	68.1
				Rear	642	26.1	79.9	13.9	13.9	
			50	Front	635	39.2	79.7	19.8	19.9	86.4
				Rear	632	33.7	80.3	17.1	17.2	
Monofacial PERT*			-	Front	656	39.8	80.0	20.9	21.1	-
pPassDop*	244	p-type Cz-Si	65	Front	638	39.1	79.4		19.8	88.9
				Rear	635	34.6	79.8		17.6	
Monofacial TOPCon*	4	n-type FZ-Si	-	Front	725	42.5	83.3		25.7	-
Bifacial SHJ [†]	244	n-type FZ-Si	50	Front	738	38.9	81.5		23.4	93.6
		51		Rear	738	35.7	83.2		21.9	

* Fraunhofer ISE solar cells; ^T Meyer Burger solar cells

Table 1. Open-circuit voltage V_{oc} , short-circuit current density j_{sc} , fill factor *FF*, energy conversion efficiency η , and bifaciality factor η_{rear}/η_{front} for various solar cell groups.

Cz-Si have been reported to achieve conversion efficiencies of up to $\eta = 21.0\%$ [34,35] (measured on a black non-conductive chuck). Beyond enabling the bifacial application, a further advantage of biPERC solar cells compared with PERC cells is a reduced consumption of aluminium paste.

When the full-area rear metallization is reduced to an aluminium grid with thin finger contacts, there are challenges associated with aligning the laser contact opening (LCO) and with the screen-printing step. Fig. 4 shows the rear view of a screen-printed aluminium finger grid, with finger widths approaching 100µm and a successful alignment with the underlying LCO. In this case, the rear features a very smooth surface, typical of monofacial PERC devices. The rear capping layer thickness has been reduced in order to serve as an antireflection coating, although it has not yet been fully optimized, as can be deduced from its optical appearance.

Table 1 shows the current-voltage (I-V) parameters for monofacial illumination, measured with contact bars on a black non-conductive chuck, of different solar cells featuring different rear-side finger widths. The results for optional monofacial reference cells are also shown for comparison. The monofacial reference for the biPERC cells features a thicker rear capping layer and a full-area aluminium metallization serving

as a reflector, increasing the optical generation and thus the short-circuit current density j_{sc} . The biPERC cells feature a reduced capping layer thickness that serves as an antireflection coating. As can be seen, the bifacial and the monofacial cells achieve similar efficiency levels of around 21%, where lower j_{sc} and FF for the bifacial cell are compensated by $V_{\rm oc}$ gains. The higher $V_{\rm oc}$ is due to the lower recombination-active local contacts for the line-shaped aluminium fingers than in the case of full-area aluminium metallization [36]. By reducing the finger width from 200 μ m to 100 μ m, the mean front efficiency $\eta_{\rm front}$ drops moderately, from 20.9% to 20.7%, as a result of an increased finger resistance. In contrast, the mean rear efficiency $\eta_{\rm rear}$ increases significantly, from 13.8% to 15.9%. The bifaciality factor, defined by the ratio of η_{rear} and η_{front} , hence increases from 66.0% to 76.8%.

Compared with a biPERC device, the bifacial passivated emitter, rear totally diffused (biPERT) solar cells exhibit a full-area BSF on the rear side; the idea here is to exploit the additional conductivity by increasing the separation of the contacts (Fig. 3(d)). In the case of a p-type base, the presence of the BSF reduces the need for heavy base doping; in consequence, a lighter-doped material, which is less prone to light-induced boron-oxygen-related degradation, can be used. Moreover, the BSF enables the use of alternative pastes for the rear contact, for example silver-aluminium or even pure silver pastes, the latter typically being used for front-side contacts on phosphorus-doped emitters.

Recent developments have put the PERT approach back into the spotlight. Chemical vapour deposition (CVD) technology enables the application of a borosilicate glass (BSG) layer and a capping layer prior to the conventional tube furnace diffusion in a POCl₃ atmosphere. During this (co-)diffusion process [36–38], both the BSF and emitter are formed. Furthermore, the remaining rear stack of BSG and capping remains on the wafer, acting also as a passivation and anti-reflection layer. The use of firing-through pastes means that LCO prior to metallization can be omitted, thus also removing the need for alignment between the laser and screen printer.

The biPERT section in Table 1 shows the *I*–V-related parameters obtained by exploiting the benefits of co-diffusion. The base doping of these cells is of the order of 4Ω cm, showing that lightinduced degradation due to boron– oxygen complexes is significantly reduced. The cells are fully solderable and resemble the appearance of the biPERC cell shown in Fig. 4. Because of the thinner rear-side fingers with biPERT, higher bifaciality factors (in this example 86.4%) can be achieved than with biPERC.

One of the first proofs-of-concept for the 'pPassDop' PERL approach on solar cells with an edge length of 156mm yields $\eta_{\rm front} = 19.8\%$ [39] (see Fig. 3(e) and Table 1). This solar cell achieves a high bifaciality of about 89% because of the rear-side grid with thin contact fingers of only around 65µm in width. The applied 'pPassDop' layer stack consisting of AlO_x/SiN_x :B on the cell's rear side serves as both surface passivation and doping source. Laser processing is used to locally introduce boron atoms from the 'pPassDop' layer stack into the silicon, which results in a boron-doped BSF underneath the rear screen-printed and fired contacts. A special alignment procedure ensures that the rear grid with finger widths of about 65µm is placed over the entire wafer on top of the ~40µm-wide laser-doped and opened lines.

Silicon heterojunction (SHJ) technology (Fig. 3(f)) is also a promising candidate because of its already bifacial design (bifaciality factors above 90%), excellent passivation quality, and highefficiency potential of up to 25.1% for lab-scale solar cells [40]. Largearea bifacial SHJ cells (with busbarless metallization) are available on the market, with efficiencies of up to 23.4% [41], and can thus also serve as a candidate for stripe cells. To close the efficiency gap between PERC-like structures and SHJ while maintaining low-cost processing, next-generation hybrid PERC structures with tunnel oxide passivated contacts (TOPCon) are already being developed on labscale solar cell sizes with an optional bifacial design; the design concept is illustrated in Fig. 3(g). The monofacial TOPCon cells currently achieve record efficiency values of 25.6% on a lab scale [42]. The TOPCon approach is currently being transferred to largearea wafers and a bifacial structure, and is expected to be market ready in the near future.

Technology-specific challenges

Despite the solar cell concepts for shingling technology being quite diverse, they will all face the separation process step, the potential need for edge passivation, and finally the integration into a module.

Separation

The quality of the separation of the solar cell stripes is closely related to edge recombination, as the separation process may induce damage to the Laser scribed cross-section Cleaved cross-section

Figure 5. A light-microscope image of a laser-scribed and mechanically cleaved edge of a silicon solar cell.



Figure 6. An illustration of the TLS process, showing the crack initiation, laser heating and fluid cooling steps leading to the substrate separation. (Image taken from Lewke [45].)

	Contour/area [1/cm]	j _{02,edge} [nA/cm ²]
25×156 mm ² stripe	0.93	12.1
50×156 mm ² stripe	0.53	6.9
$156 \times 156 \text{mm}^2 \text{ cell}$	0.26	3.3

Table 2. Example calculations for contour-to-area ratio and resulting $j_{02,edge}$ (after Dicker [47]), showing that a 25mm-wide stripe has a fourfold influence on $j_{02,edge}$ recombination, compared with a regular square cell (in the case of an unpassivated edge).

	S _{eff} [cm/s]	j _{02,edge} [nA/cm]
Unpassivated edge	10 ⁶	13
Passivated edge	10	0

 Table 3. Applied recombination levels for the cell edges, representing unpassivated and passivated edges.

edge and leaves a surface with a process-dependent damage density and roughness. In the case of SPEER and SPEERCon cells, edge recombination becomes significant because of the high contour-to-area ratio (see next section). The most common method used so far for silicon solar cell separation has been laser scribing, followed by mechanical cleavage [12]. For example, the pulsed laser source engraves about one-third of the cell thickness (usually from the rear side) in the scribing phase [43]; the complete separation of the rest of the solar cell occurs mechanically in the final cleaving step. Fig. 5 shows an example of a cross section of an

edge to illustrate the difference in the surface morphology remaining in the scribed and cleaved areas.

Recently, with the increase in half- and quarter-cell production demand [15], thermal laser separation (TLS) [43,44] was proposed as a candidate for future silicon substrate dicing [44]. TLS is a kerf-free, laser-based dicing technology that is based on crack guiding by means of thermally induced mechanical stress [43] (see Fig. 6). This technology is widely used in the semiconductor industry [44]. Briefly, TLS is a two-step process [43], starting with an initial scribe (less than 50μ m deep) using a laser source to induce a crack. The second step is the crack guidance. The laser-induced substrate heating creates a compressive stress, followed by a subsequent fluid cooling, which incites tensile stress.

The TLS method of separating silicon wafers has been reported to show a higher edge quality; in initial TLS tests performed on PERC solar cells to obtain half-cells it has been found that this method leads to improved electrical and mechanical properties compared with conventional laser-scribed and cleaved half-cells [44,45]. There have been statements to the effect that the half-cells separated by the TLS process have shown a $1\%_{\rm rel}$ reduction in maximal power, whereas the half-cells separated by conventional laser scribing and cleaving have shown a $1.2\%_{\rm rel}$ power reduction.

To gain a deeper understanding of the TLS parameters [43,44] and their effects on the quality of the edges of the separated stripe cells, further development within the PV production research community is expected. An optimized process should be aimed at creating a very smooth surface as a good basis for subsequent passivation. The introduction of such a laser process into the process chain for the separation of the cell stripes could decrease the recombination of the stripes' edge regions, which will be discussed in the next section.

Edge passivation

As mentioned in the previous section, the singulated solar cell stripes have a larger contour-to-area ratio than standard (pseudo-)square cells, which is illustrated in Table 2 for 2.5cm- and 5cm-wide stripes. Moreover, (pseudo-)square cells undergo a passivation process which also covers the edges, while the stripes are singulated after metallization and contact formation, leaving the edges initially blank. This poses the question of potential losses through recombination at those edges, which can be divided into three subregions:

- 1. Surfacing bulk region, implicating ideal surface recombination (ideality factor n = 1). This can be accounted for with modelling by using an effective surface recombination velocity between $S_{\rm eff} \approx 8 \, {\rm cm/s}$ for excellent passivation (e.g. reported by Saint-Cast et al. [46]) and $S_{\rm eff} = 10^6 \, {\rm cm/s}$ for an unpassivated surface (with high defect density, reported by Glunz and Dicker [12,47]).
- 2. Surfacing heavily doped emitter region, implicating ideal surface recombination.
- 3. Surfacing space charge region (SCR), implicating nonideal surface recombination activity (ideality factor $n \approx$ 2). Dicker parameterized this recombination for a single recombining edge using the second diode in the twodiode model, naming it $j_{02,edge}$ [47]. This recombination current density comprises a determined constant of 13nA/ cm scaling with the contour-to-area ratio, so that $j_{02,edge}$ = contour/area·13nA/cm². A very similar value has been recently found by Fell et al. [48]. This yields the $j_{02,edge}$ values given in Table 2 for the example stripes.



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For the examined cells, Dicker [47] concluded that the surfacing bulk region recombination and the SCR recombination contribute equally to the total edge recombination, whereas the emitter region surface recombination has a negligible influence because of its small extent.

In the particular case presented here, it is desired to calculate the worst case of all four edges of the stripe cell being recombination active. To model these effects, the newly developed Quokka3 tool (currently in beta stage, with release planned in 2017) will be used. Because a lumped skin approach (an expression originally coined by Cuevas et al. [49]) is used for non-neutral regions, the mesh fineness can be reduced to a minimum. In consequence, this allows the modelling of much larger domains, in this case an entire cell stripe, resulting in a generalized model without spatial simplifications such as potential or series resistance distributions (as opposed to the usual one-cell approach). With the





frontfinge



designated area

cell 2



Figure 7. 3D model of a bifacial SPEER solar cell.

rearfing

latest addition of a vertical resistance and full injection dependence on the skin parameterization [25], the skins can be described by lumped parameters without errors, compared with, for example, explicitly accounting for doping profiles. The cell stripe CAD model is depicted in Fig. 7.

"The goal of the cell optimization is to find the ideal cell stripe width and determine the impact of edge recombination."

The input parameters are extracted from a bifacial PERC solar cell that has been processed on the Fraunhofer ISE PV-TEC pilot line, yielding a front-side efficiency of 21% under 1,000W/m² AM1.5g illumination and with a bifaciality of 75% (see Table 1); these parameters are then applied to the stripe cell, which is based on the same processes. The goal of the cell optimization is to find the ideal cell stripe width and determine the impact of edge recombination. Three scenarios are therefore simulated while varying the stripe width, beginning with a stripe cell with a highly recombinational edge ($S_{\rm eff}$ and j_{02} as shown in Table 3).

As shown in Fig. 8, the busbar, as well as the adjacent area, is covered by an active area of the overlying cell; thus, only the marked designated area is relevant in the determination of the $j_{\rm sc}$. In step one ('1' in Fig. 9), this effect due to shingling in the module is included in the simulated I-V parameters. The second step ('2' in Fig. 9) introduces an excellent edge passivation, assuming $S_{\rm eff} = 10 \,{\rm cm/s}$ and $j_{02,\rm edge} = 0 \,{\rm nA/cm}$. All the results shown were calculated for a bifacial illumination with a front irradiance of $1,000 \,{\rm W/m^2}$ and a rear irradiance of $100 \,{\rm W/m^2}$ (which is presumed to be a candidate for a coming standard for bifacial I-V measurements).

Step 1 has a major effect on $j_{\rm sc}$, but the dependence on the stripe width vanishes as the continuous shading of the busbar is diminished. Moreover, $j_{\rm sc}$ shifts by around 1mA/cm², to 43.7mA/cm², which reflects one aspect of the advantages of shingling technology. Step 2, the edge passivation, manifests its effect mainly in *FF* and $V_{\rm oc}$. Reduced SCR recombination at the edges $j_{02,\rm edge}$ leads to a jump in *FF* by 2–3%_{abs} for small stripes; the reduced base edge recombination $S_{\rm eff}$ increases $V_{\rm oc}$ by 10–15mV for small stripes. Both effects are pronounced for small stripes as a result of their higher contour-to-area ratio.

Step 1 increases the overall power output P_{out} of the stripe cell from 22 to 22.5mW/cm² at an ideal stripe width of 25mm, and reduces the sensitivity to variations in stripe width. Step 2 increases P_{out} to 23.6mW/cm² at a stripe width of 25mm. It increases further with smaller stripe widths, but this is not a suitable approach for cell interconnection, as will be shown in the next section. Overall, with a gain of more than 1mW/cm² it is well worth considering an additional process step for edge passivation. The implementation of such an edge passivation technique, which is in the best case also suitable for mass production, is currently a high-priority line of investigation in the ongoing work at Fraunhofer ISE.

Module integration and CTM loss analysis

As described above (see Fig. 8), the electrical interconnection of solar cells in shingled modules is achieved by overlapping and directly connecting the n and p sides of adjacent solar cells. To increase electrical performance, an electrically conductive adhesive (ECA) or solder paste may be used between the cell stripes [13]. The depth of the overlap is observed to be between 1 and 2mm. A trade-off in overlap between manufacturing requirements (cell lay-up





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precision) and costs (shaded cell parts do not generate power, but still have to be purchased) needs to be examined, which is crucial for the module's power/price ratio. The same argument is valid for the size of the shingled cells: although smaller cell stripes decrease some electrical losses because of lower current generation, as shown in the previous modelling, they increase manufacturing requirements, the proportion of overlapped area, and edge recombination losses.

Figure 10. Different module topologies with serial, parallel and combined string interconnection, and single and separate junction boxes.

Since all cells are directly connected, a string of significant length without gaps or compensating





elements is formed. At changing temperatures, thermomechanical stress occurs within the cell interconnection and the cell metallization. While the stress from external loads (e.g. snow) may be reduced by placing the solar cells in the neutral plane of double-glass modules, the thermomechanical stress resulting from different coefficients of thermal expansion cannot be avoided. The direct overlapping of the cell

stripes eliminates the cell gaps, and therefore increases the active module area proportion. Two options are possible to take advantage of the resulting gains: 1) reduce the module size, keeping the module power constant and saving on module area and materials; or 2) keep the module area constant and increase power and efficiency. For typical set-ups, either approximately 9% more power than a conventional module can be generated, or the module area can be reduced.

As a result of the increased number of (smaller) solar cells in shingled modules, the module voltage increases if a conventional module topology that connects strings of solar cells in series (Fig. 10) is used. To be compatible with existing inverters, and so as not to exceed electrical limitations, electrical properties similar to conventional PV modules are desirable. New module topologies featuring strings connected in parallel, or using combinations of parallel and serial cell and string interconnection, are therefore necessary and have been discussed in the literature [8,50,51].

Shingling requires new solutions for string interconnection, junction boxes and bypass diode placement.

"Shingling requires new solutions for string interconnection, junction boxes and bypass diode placement."

Shingled modules are a concept that is certainly capable of producing increased module efficiency and module power. A detailed CTM analysis using SmartCalc.CTM by Fraunhofer ISE [52] (also presented in another article in this issue of *Photovoltaics International*. p.97) reveals important gains and losses as well as several major differences with conventional modules.

First, a few remarks on the CTMloss calculations have to be made. Shingling is the only crystalline module concept in which the active cell area may be shaded by another active area. The overlapping cell area usually has a higher efficiency, since the overlapped cell area features metallization patterns for interconnection.

Let us assume that two cells of the same power are completely overlapped, and that the lower cell is fully shaded and therefore produces no electrical power. Now, only one 'power unit' remains after this overlapping. Since the reference area has also changed, the efficiency remains the same (CTM_{efficiency} = 1). Because initially (before overlapping) two power producing cells were present, the CTM factor for *power* has changed and is now CTM_{power} = 0.5. With shingling, therefore, the CTM factors for power and efficiency do not correspond as they do with other module concepts.

Usually, the absolute power loss is higher for a shingled module than for a conventional one, but so is the sum of the initial cell powers, since more cells are needed to cover the module and the overlapping areas. Figs. 11 and 12 illustrate the higher absolute CTM losses for shingled modules. Nevertheless, shingled modules are capable of achieving higher module powers and efficiencies than conventional modules [53].

Shingled modules do not include interconnection ribbons; thus, there are no electrical losses associated with ribbons, but contact and bulk resistance losses in the ECA occur. Optical gains and losses remain practically unchanged from those of conventional modules, with the exception of backsheet reflections (k11) and potential reflective gains from interconnection ribbons (k10). Electrical mismatch losses are heavily dependent on the manufacturing equipment and the homogeneity of the cell stripes [54].

SmartCalc.CTM was used to analyse the CTM ratio of a shingled module using the modelled bifacial PERC cells described above; results of the analysis are shown in Fig. 11. The module features six strings of 67 shingled cells with dimension 25mm



× 156mm. Each cell has a power of 1W ($P_{out} = 23.2 \text{mW/cm}^2$ at 1,000W/ $m^2\ front-side$ and $100W/m^2\ rear$ side irradiance), which corresponds to the black line in Fig. 9 at 25mm, calculated using a full area instead of a designated area. Commercially available module materials - such as EVA, AR-coated glass and a polymer backsheet - are used. The overlap of the cells is set to 2mm; reducing this value would greatly reduce the total power loss from cell to module, but not the final module power. A module with SPEER cells would produce 376W $(P_{\rm out} = 21.9 \,{\rm mW/cm^2}).$

Full-size biPERC solar cells were used in a conventional module set-up (H-pattern, ribbon interconnection, 205mm pseudo-square, 6W per bifacial cell), and a comparative CTM analysis of both module concepts was performed. Results of the ribboninterconnected PERC cells are shown in Fig. 12. A conventional ribboninterconnected module – featuring solar cells with the same biPERC technology as the previous SPEER cells – would only produce 361W.

Since an overlap of the shingled cells of 2mm was chosen, a larger number of cells is necessary for the shingled module (402Wp, Fig. 11). At this point, cost considerations become important and further module optimization is supported with SmartCalc.CTM.

To obtain a module power with the conventional module set-up that is similar to the power that can be achieved with the shingle concept, an increase in the initial cell performance is necessary for H-pattern biPERC cells. Bifacial H-pattern cells with 24.2mW/cm² at 1,100W/m² irradiance (an increase of 1.0mW/ cm² compared with the SPEER cells for shingling) would be required to also achieve a module power of 376W. As the approach here features stripe cells based on the specific process technology for large-area cells, the power of the shingled module will automatically surpass that of the conventional module technology by around this margin, even if the cell efficiencies improve.

The next step to reaching the target of 400W per module (at an area of a common 60-cell module) is to perform an estimation of the necessary cell power to achieve this goal. A detailed CTM analysis is shown in Fig. 13.

A parameter sweep of the electrical cell characteristics reveals that SPEER cells with 1.06Wp ($P_{out} = 24.7$ mW/ cm²) are required if a shingled module set-up as described above is used. Dividing that output power by 1.1 (irradiance factor), and neglecting

the bifaciality factor, the approximate front-side efficiency for such a cell would be $\eta = 22.5\%$. This is a number which, according to the ITRPV roadmap [15], is to be expected for mass-cells produced by 2021, and has in fact already been achieved for full-size pseudo-square PERC record cells ([55], $\eta = 22.61\%$). Furthermore, if the next-generation cell concepts discussed above, such as SHJ, are integrated in shingled modules, then powers exceeding 400W in standardsize modules can definitely be expected.

Summary

PV modules with shingled cell technology have a history almost as old as the silicon solar cell itself. With bifacial PERC or PERC-like solar cells, industrially available concepts are at hand that now put shingling technology into an attractive position. A cost-effective cell concept can be boosted by the bifacial shingled module concept towards achieving the module power benchmark of 400W, for a conventional ('60-cell') module size with 1,000W/m² front and 100W/ m² rear irradiance, by reducing CTM losses and benefitting from bifacial irradiance gains.

Some of the challenges faced on the path to realizing a bifacial shingled module have been highlighted:

- 1. Achievement of a monofacial cell efficiency of 22.5% (standard test conditions, 1,000W/m² irradiance) in mass production, which is supposed to be reached by PERC/ PERT/PERL R&D in the next two years as a result of industry selfinterest.
- 2. Provision of suitable cell separation techniques and/or reduction in edge recombination through appropriate passivation methods.
- 3. Development of reliable shingled cell interconnection and precise module assembly to guarantee durability and minimum mismatch in the module.

"It is the authors' belief that the combination of shingling and bifacial technology offers the greatest and most accessible levers for power output increases in solar modules."

The modularity of the shingling module concept, together with the availability of the presented hybrid PERC (TopCon) or silicon heterojunction concepts, furthermore implies the possibility of even higher module powers, which are basically a bonus when the module concept for biPERC has been developed. Overall, this is encouraging in the development of a product suitable for the industrial and consumer markets, because it is the authors' belief that the combination of shingling and bifacial technology offers the greatest and most accessible levers for power output increases in solar modules. The recent appearance of the first shingled modules from large manufacturers seems to support the considerations discussed in this paper.

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